Form PTO-1449 U.S. DEPARTMENT OF COMMERCE (REV. 7-80)PATENT AND TRADEMARK OFFICE				Atty. Docket No. YOR919950251US3 (14784AB)			Serial No. To be assigned			
LIST OF PRIOR ART CITED BY APPLICANT				Applicant 10658036 Nancy A. Greco, et al.						
(Use several sheets if necessary)				Filing Date 9/9/03			Group 2-813			
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EXAMINER										
• EXAMINER Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance										

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